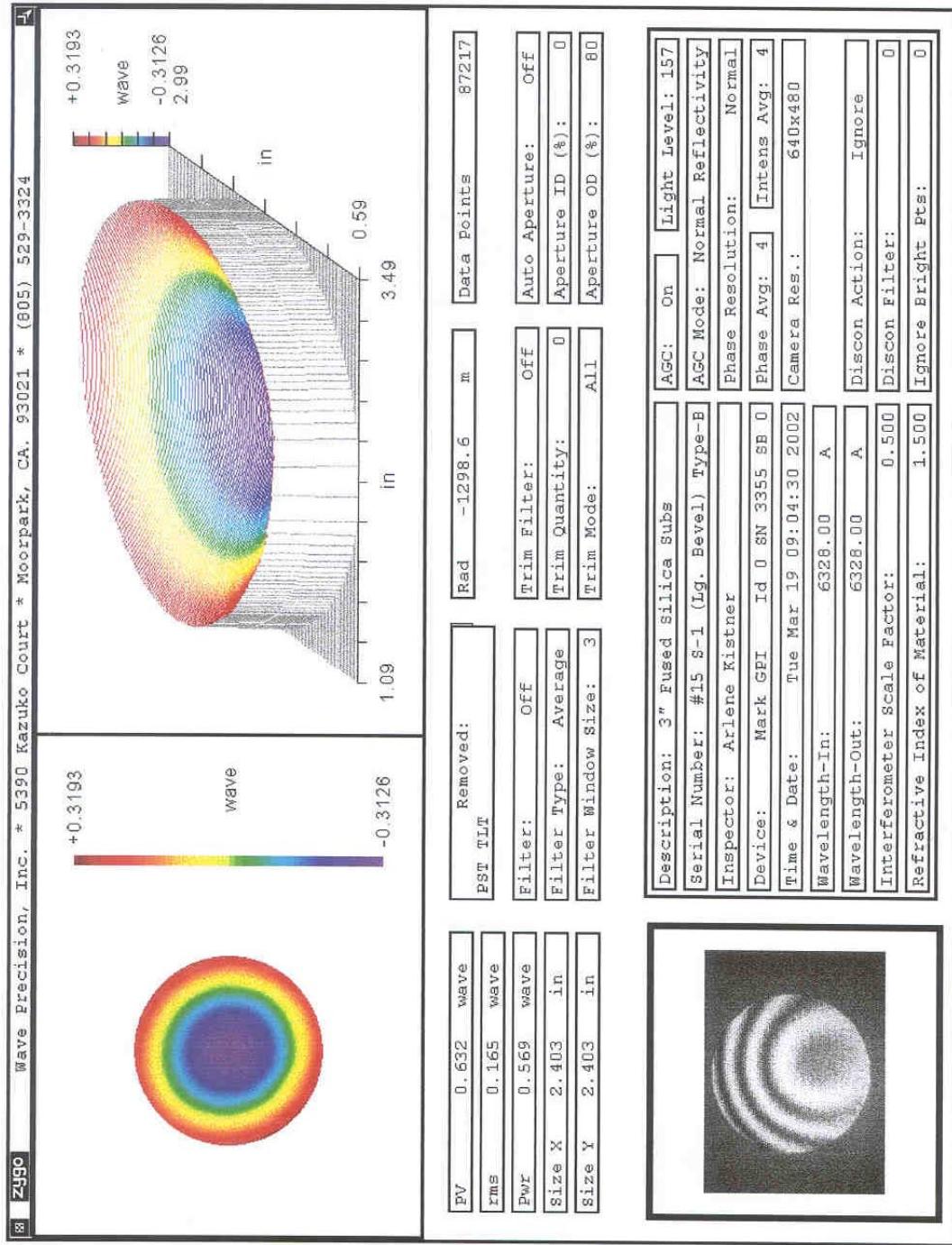


3" dia. x 0.100" substrate S/N 15 before coating



3" dia. x 0.100" substrate S/N 15 after coating

MLID Technologies, LLC

Tel (650)938-3780 Fax (650)938-3113

Cust. LIGO

PO 1039272

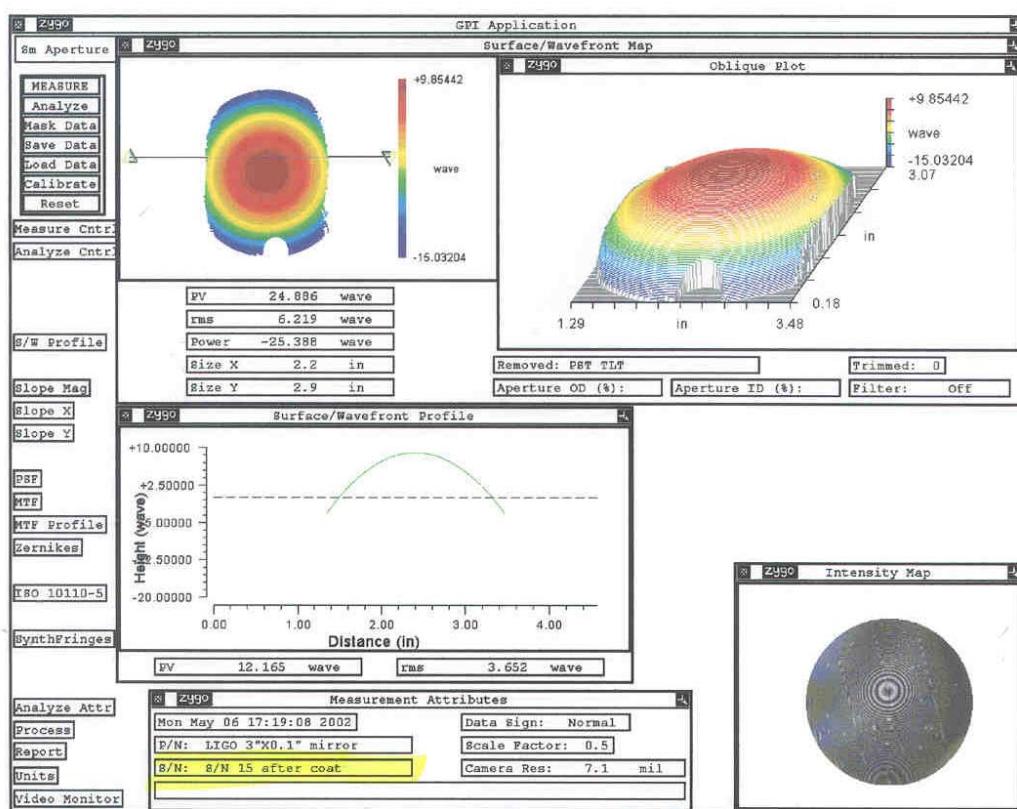
P/N 30 Layer Ta₂O₅/SiO₂

Qty.

Date July 9, 2002

Run # 13249

Ta₂O₅/SiO₂



3" dia. x 0.100" substrate S/N 15 after annealing at 450 degrees C for 24 hr

